

	L #	Hits	Search Text
1	L1	86831	(mask or reticle) and (wafer or substrate)
2	L2	129	(first adj stage) same (second adj stage) same electromagnetic
3	L3	4	((rough near2 stage) or (scanning adj stage)) same (fine near2 stage) same electromagnetic
4	L4	6	(2 or 3) and 1
5	L5	11	(fine near2 stage) same (electromagnetic or electro-magnetic)
6	L6	130	(first adj stage) same (second adj stage) same (electromagnetic or electro-magnetic)
7	L7	11	(5 or 6) and 1
8	L8	214	(second adj stage) same (electromagnetic or electro-magnetic)
9	L9	14	(5 or 8) and 1
10	L10	8	9 not 4
11	L11	1313	(second near2 stage) same (accelerat\$4)
12	L12	36	(fine near2 stage) same (accelerat\$4)
13	L13	60	(11 or 12) and 1
14	L14	21	13 and (355/\$.ccls. or 310/12.ccls. or 310/53.ccls. or 356/399-401.ccls. or 74/490.09.ccls.)

R/K

10/15/02